

PROCEEDINGS OF SPIE

*Photonics and Optoelectronics
Meetings (POEM) 2009*

Optoelectronic Devices and Integration

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Editors

**8–10 August 2009
Wuhan, China**

Organized by
Wuhan National Laboratory for Optoelectronics (China)

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Published by
SPIE

Volume 7516

Proceedings of SPIE, 0277-786X, v. 7516

SPIE is an international society advancing an interdisciplinary approach to the science and application of light.

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Author(s), "Title of Paper," in *Photonics and Optoelectronics Meetings (POEM) 2009: Optoelectronic Devices and Integration*, edited by Zishen Zhao, Ray Chen, Yong Chen, Jinzhong Yu, Junqiang Sun, Proceedings of SPIE Vol. 7516 (SPIE, Bellingham, WA, 2009) Article CID Number.

ISSN 0277-786X

ISBN 9780819479051

Published by

SPIE

P.O. Box 10, Bellingham, Washington 98227-0010 USA

Telephone +1 360 676 3290 (Pacific Time) · Fax +1 360 647 1445

SPIE.org

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Printed in the United States of America.

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